Comment on “Scaling of the Interface Roughness in Fe-Cr Superlattices: Self-Affine versus Non-Self-Affine”

In a recent Letter, Santamaria et al. presented the first clear evidence for anomalous scaling of the interface roughness in sputtered metal-metal superlattices [1]. They observed that the scaling exponents did not fit in any of the existing model classes of surface growth that are known to exhibit anomalous scaling, and attributed the discrepancy to kinetic roughening being more complex in superlattices than in single films. Here we show that this explanation is unconvincing, since single films also exhibit anomalous scaling incompatible with the models quoted in [1], and qualitatively similar to that observed for superlattices.

Figure 1 shows the root-mean-square surface width $\sigma$ averaged over squares of side $l$, for Cu films prepared by electrodeposition from an alkaline 0.18 M CuSO$_4$/0.25 M K$_2$P$_2$O$_7$ electrolyte on Au(25 nm)/Ti(5 nm)/glass substrates, and measured by atomic force microscopy. Note that the position of the crossover between power-law behavior ($\sigma \propto l^{\beta_{loc}}$) and saturation ($\sigma = \sigma_{sat}$), which is a measure of the lateral correlation length $l_c$, remains nearly constant as the deposition time, and correspondingly the film thickness increases. This indicates that the long and short length-scale dynamic exponents $\beta$ and $\beta_{loc}$ are approximately equal, which is exactly the behavior noted by Santamaria et al. [compare Fig. 1(b) of [1] for columnar superlattices deposited at low-pressure (4–6 mTorr), although the value of $\beta$ is considerably larger in the electrodeposition case ($\beta = 0.78 \pm 0.02$).

Furthermore, electrodeposited Cu films can also show very similar scaling behavior to that determined for Fe-Cr superlattices deposited at high pressure (8–10 mTorr) [1]. Values of $\alpha_{loc} = 0.75 \pm 0.05$, $\beta_{loc} = 0.22 \pm 0.05$, and $\beta = 0.76 \pm 0.05$ were reported for the superlattices, while values of $\alpha_{loc} = 0.78 \pm 0.05$, $\beta_{loc} = 0.21 \pm 0.03$, and $\beta = 0.57 \pm 0.05$ have been previously reported for Cu films electrodeposited from an organic additive-free acid CuSO$_4$ electrolyte [2].

Although the two sets of Cu films were both grown on the same substrates, those deposited from the acid electrolyte that show scaling similar to the Fe-Cr superlattices grown at high pressure were nanocrystalline, while those deposited from the alkaline electrolyte that show scaling qualitatively similar to the Fe-Cr superlattices grown at low pressure were, similar to the superlattices, columnar. Clearly, kinetic roughening can be more complex in superlattices than in single films but, given the similarities between the experimental scaling data for electrodeposited single films and sputtered superlattices with similar microstructures, we suggest a more important reason why both may disagree with model predictions: The latter do not take microstructure, in particular, grain formation, into account.

W. Schwarzacher* and S. Huo†
H. H. Wills Physics Laboratory
Tyndall Avenue
Bristol BS8 1TL, United Kingdom

Received 17 December 2002; published 12 September 2003
DOI: 10.1103/PhysRevLett.91.119601
PACS numbers: 68.55.Jk, 05.40.–a, 81.10.Aj, 81.15.Cd

*Electronic address: w.schwarzacher@bristol.ac.uk
†Present address: Seagate Technology, 1 Disk Drive, Springtown, Northern Ireland.
